

Notice of References Cited		Application/Control No. 10/538,763	Applicant(s)/Patent Under Reexamination SLONAKER, STEVEN DOUGLAS	
		Examiner KIBROM K. GEBRESILASSIE	Art Unit 2128	Page 1 of 2

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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
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